# Special Issue

## Advanced Functionally Graded Materials

### Message from the Guest Editors

This Special Issue "Advanced Functionally Graded Materials" aims to gather cutting-edge research at the intersection of material science, additive manufacturing, and engineering applications. We welcome contributions focused on the development, characterization, and application of functionally graded materials across various domains. Topics of interest include, but are not limited to, the following: -
Functionally graded materials and metamaterials;
- Performance analysis and simulation techniques;
- Integration of machine learning approaches;
- Exploration of porous materials and structures;
- Advancements in carbon nanotube-reinforced composite materials;
- Comprehensive modeling and analysis of materials and structures.

### Guest Editors

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### Deadline for manuscript submissions

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### Editor-in-Chief

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